

AMENDMENTS TO THE SPECIFICATION:

Please amend the title as follows:

~~Agent A Material for Promoting the Formation of Skin Basement
Formation Membrane, Agents Promoting the Formation of Artificial
Skin and Process for Producing Artificial Skin~~

Please amend the paragraph beginning at line 6 of page 1
as follows:

This application claims the priority of Japanese Patent
Application No. 2000-87574, filed on March 27, 2000, which is
incorporated herein by reference. This application is a
continuation of serial number 09/979,712, filed on November 26,
2001 and later abandoned.

Please amend the Abstract found on page 32 as follows:

~~The present invention discloses an artificial skin formation~~
A method for promoting agent and skin basement membrane
~~stabilizing agent comprising~~ formation comprises administering

matrix metalloproteinase inhibitor or matrix metalloproteinase inhibitor and matrix protein production promoting agent. The matrix metalloproteinase inhibitor is N-hydroxy-2(R)-[[(4-methoxyphenyl)sulfonyl] (3-picolyl) amino] -3-methylbutanamide hydrochloride. ~~as well as a production method of artificial skin comprising adding matrix metalloproteinase inhibitor or matrix metalloproteinase inhibitor and matrix protein production promoting agent to an artificial skin formation medium.~~